

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	98331	(photosensitive or photoresist or photolithographic or lithographic) same (resin or polymer or copolymer)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/19 07:39
L2	872	polybenzoxazole same (polyimide or hydroxypolyamide)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/19 08:11
L3	228	1 and 2	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/11/19 08:12

Refine Search

Search Results -

Terms	Documents
Jp-2002012665-\$.did.	2

Database:

US Pre-Grant Publication Full-Text Database
US Patents Full-Text Database
US OCR Full-Text Database
EPO Abstracts Database
JPO Abstracts Database
Derwent World Patents Index
IBM Technical Disclosure Bulletins

Search:

L1

Refine Search

Recall Text

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Search History

DATE: Friday, November 19, 2004 [Printable Copy](#) [Create Case](#)

<u>Set Name</u> side by side	<u>Query</u>	<u>Hit Count</u>	<u>Set Name</u> result set
<i>DB=PGPB,USPT,USOC,EPAB,JPAB,DWPI,TDBD; PLUR=YES; OP=OR</i>			
<u>L1</u>	Jp-2002012665-\$.did.	2	<u>L1</u>

END OF SEARCH HISTORY

Hit List

Clear	Generate Collection	Print	Fwd Refs	Bkwd Refs
Generate OACS				

Search Results - Record(s) 1 through 2 of 2 returned.

☐ 1. Document ID: JP 2002012665 A

Using default format because multiple data bases are involved.

L1: Entry 1 of 2

File: JPAB

Jan 15, 2002

PUB-NO: JP02002012665A

DOCUMENT-IDENTIFIER: JP 2002012665 A

TITLE: PHOTSENSITIVE RESIN AND COMPOSITION THEREOF

PUBN-DATE: January 15, 2002

INVENTOR-INFORMATION:

NAME

COUNTRY

KANEDA, TAKAYUKI

KIMURA, MASASHI

KANETANI, RYUICHIRO

INT-CL (IPC): C08 G 73/22; C08 K 5/00; C08 L 79/06; G03 F 7/038; G03 F 7/40; H01 L 21/027

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw De
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☐ 2. Document ID: JP 2002012665 A

L1: Entry 2 of 2

File: DWPI

Jan 15, 2002

DERWENT-ACC-NO: 2002-540892

DERWENT-WEEK: 200258

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TITLE: Photosensitive polybenzoxazole precursor resin preparation for insulating material of electronic parts, comprises reacting part of hydroxyl group in hydroxypolyamide with unsaturated double bond-containing isocyanate compound

Full	Title	Citation	Front	Review	Classification	Date	Reference	Claims	KWIC	Draw De
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Clear	Generate Collection	Print	Fwd Refs	Bkwd Refs	Generate OACS
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Terms	Documents